

PHAROS

High Power and Energy Femtosecond Lasers

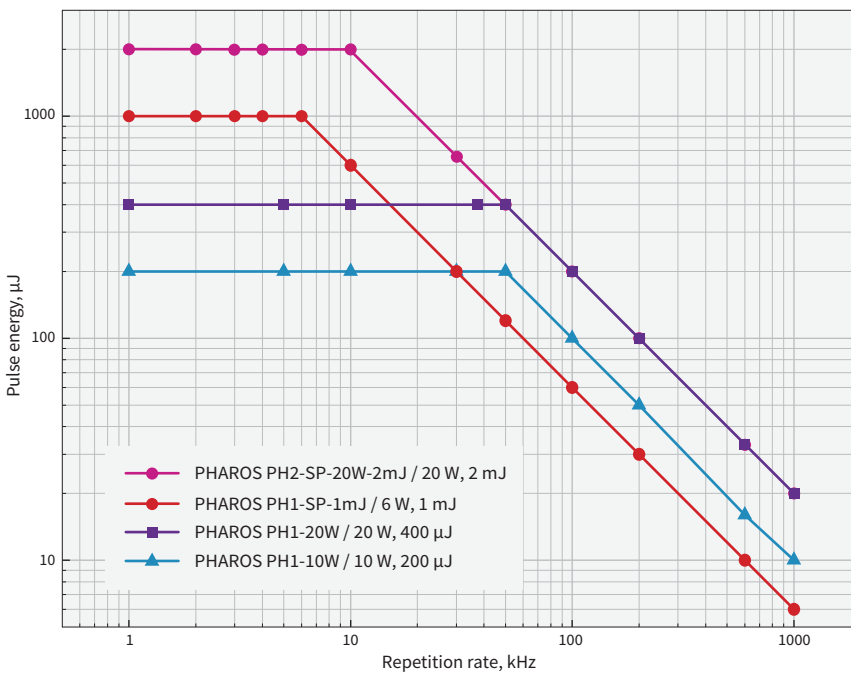
FEATURES

- 190 fs – 20 ps tunable pulse duration
- 2 mJ maximum pulse energy
- 20 W output power
- 1 kHz – 1 MHz tunable base repetition rate
- Pulse picker for pulse-on-demand operation
- Rugged industrial grade mechanical design
- Automated harmonics generators (515 nm, 343 nm, 257 nm, 206 nm)
- Optional CEP stabilization
- Possibility to lock oscillator to external clock

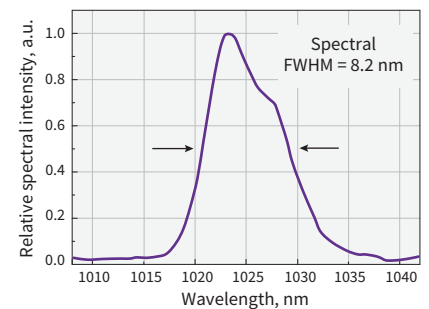


PHAROS is a femtosecond laser system combining millijoule pulse energies and high average powers. PHAROS features a mechanical and optical design optimized for industrial applications such as precise material processing. Compact size, an integrated thermal stabilization system, and sealed design allow PHAROS integration into machining workstations. Laser diodes pumping Yb medium significantly reduces maintenance costs and provides a long laser lifetime. Software tunability of PHAROS allows the system to cover applications

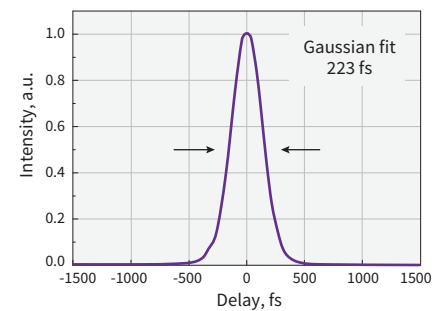
normally requiring different classes of laser. Tunable parameters include pulse duration (190 fs – 20 ps), repetition rate (single pulse to 1 MHz), pulse energy (up to 2 mJ) and average power (up to 20 W). Its power level is sufficient for most material processing applications at high machining speeds. The built-in pulse picker allows convenient control of the laser output in pulse-on-demand mode. PHAROS compact and robust optomechanical design features stable laser operation across varying environments.



Pulse energy vs base repetition rate for PHAROS



Typical spectrum of PHAROS



Typical pulse duration of PHAROS

SPECIFICATIONS

NEW

Model ¹⁾	PH1-10W	PH1-15W	PH1-20W	PH1-SP-1mJ	PH2-SP-20W-2mJ
OUTPUT CHARACTERISTIC					
Max. average power	10 W	15 W	20 W	6 W	20 W
Pulse duration (assuming Gaussian pulse shape)	< 290 fs			< 190 fs	
Pulse duration range	290 fs – 10 ps (20 ps on request)			190 fs – 10 ps (20 ps on request)	
Max. pulse energy	> 0.2 mJ or > 0.4 mJ			> 1 mJ	> 2 mJ
Beam quality	TEM ₀₀ ; M ² < 1.2			TEM ₀₀ ; M ² < 1.3	
Base repetition rate ²⁾	1 kHz – 1 MHz				
Pulse selection	Single-Shot, Pulse-on-Demand, any base repetition rate division				
Centre wavelength	1028 nm ± 5 nm			1033 nm ± 5 nm	
Output pulse-to-pulse stability ³⁾	< 0.5 % rms over 24 hours				
Power stability	< 0.5 % rms over 100 h				
Pre-pulse contrast	< 1 : 1000				
Post-pulse contrast	< 1 : 200				
Polarization	Linear, horizontal				
Beam pointing stability	< 20 µrad/°C				

OPTIONAL EXTENSIONS

Oscillator output	Optional. Please contact sales@lightcon.com for more details or customized solutions				
Typical output	1 – 6 W, 50 – 250 fs, ~1035 nm, ~ 76 MHz, simultaneously available				
Harmonics generator	Integrated, optional (see page 8)				
Output wavelength	515 nm, 343 nm, 257 nm, 206 nm				
Optical parametric amplifier	Integrated, optional (see page 15)				
Tuning range	640 – 4500 nm				
BiBurst mode	Tunable GHz and MHz burst with burst-in-burst capability, optional (see page 9)				
GHz-mode (P)					
Intra burst pulse separation ⁴⁾	~ 200 ± 40 ps			~ 500 ± 40 ps	
Max no. of pulses ⁵⁾	1 . . 25			1 . . 10	
MHz-mode (N)					
Intra burst pulse separation	~ 16 ns				
Max no. of pulses	1 . . 9, (7 with FEC)				

PHYSICAL DIMENSIONS

Laser head ⁶⁾	670 (L) × 360 (W) × 212 (H) mm	730 (L) × 419 (W) × 233 (H) mm
Rack for power supply & chiller	642 (L) × 553 (W) × 673 (H) mm	PS integrated in the laser head

UTILITY REQUIREMENTS

Electric	110 V AC, 50 – 60 Hz, 20 A or 220 V AC, 50 – 60 Hz, 10 A
Operating temperature	15 – 30 °C (air conditioning recommended)
Relative humidity	< 80 % (non condensing)

¹⁾ More models are available on request.

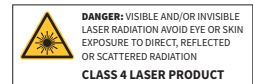
²⁾ Some particular repetition rates are software denied due to system design.

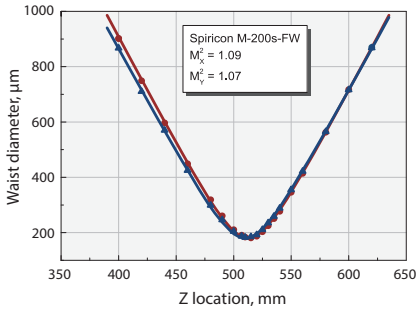
³⁾ Under stable environmental conditions.

⁴⁾ Custom spacing on request.

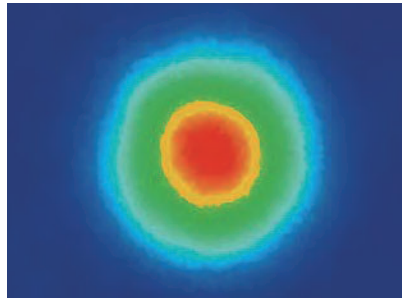
⁵⁾ Maximum number of pulses in a burst is dependent on the laser repetition rate. Custom number of pulses on request.

⁶⁾ Dimensions might increase for non-standard laser specifications.

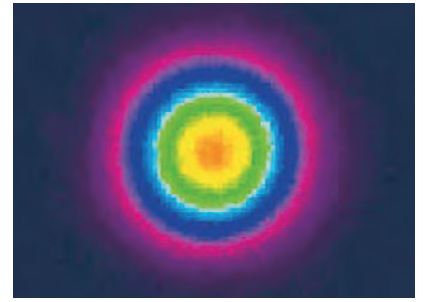




Typical M² measurement data of PHAROS

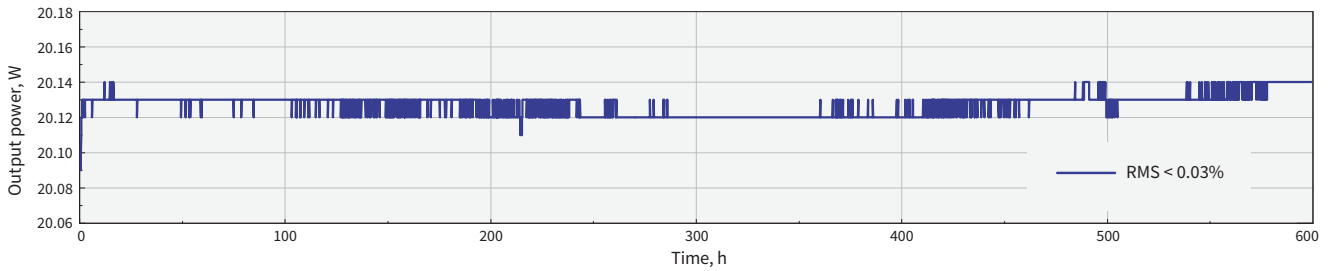


Typical near-field beam profile of PHAROS at 200 kHz

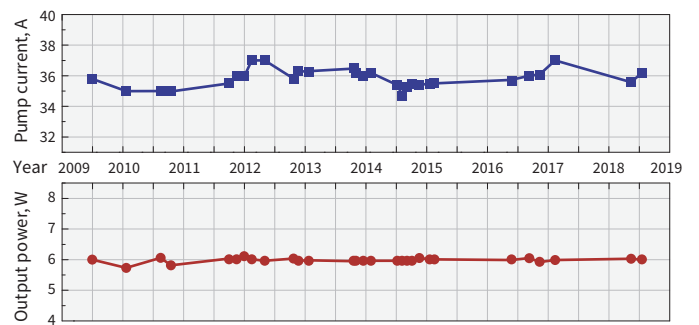
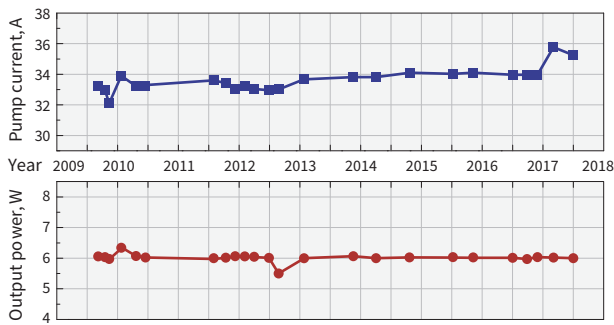


Typical far-field beam profile of PHAROS at 200 kHz

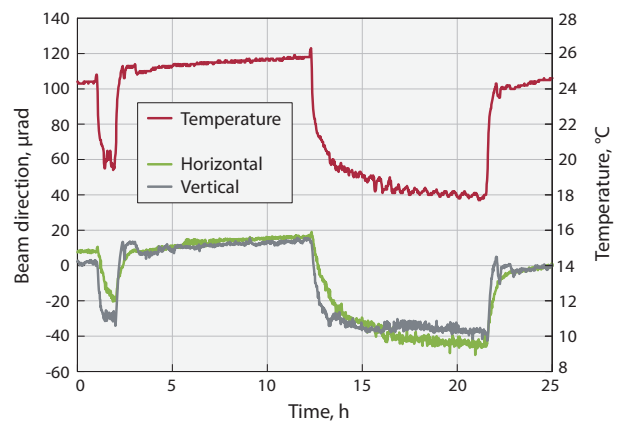
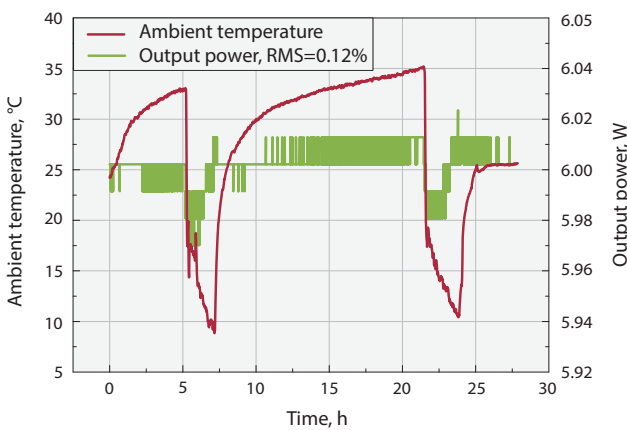
STABILITY MEASUREMENTS



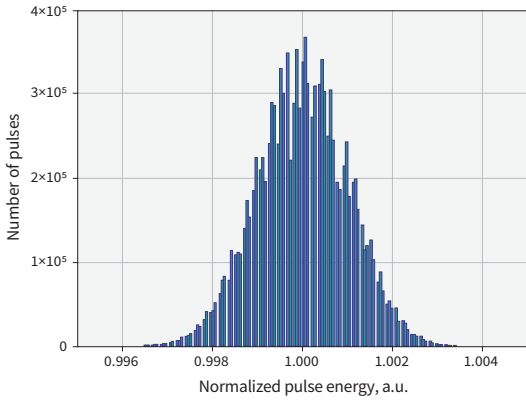
Long term stability graph of PHAROS



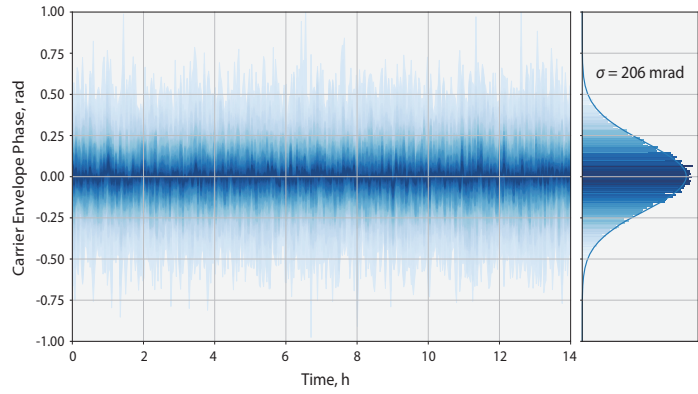
Output power of industrial PHAROS lasers operating 24/7 and current of pump diodes during the years



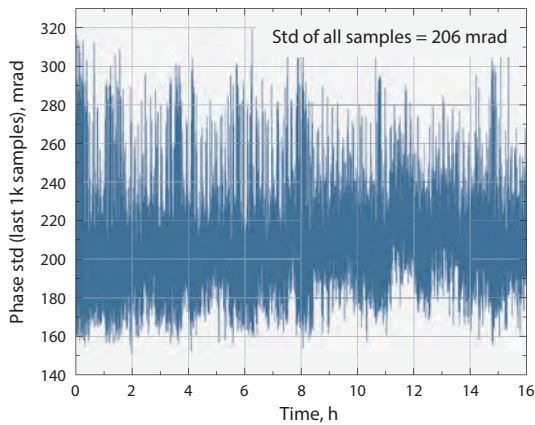
PHAROS output power with power lock enabled under unstable environment



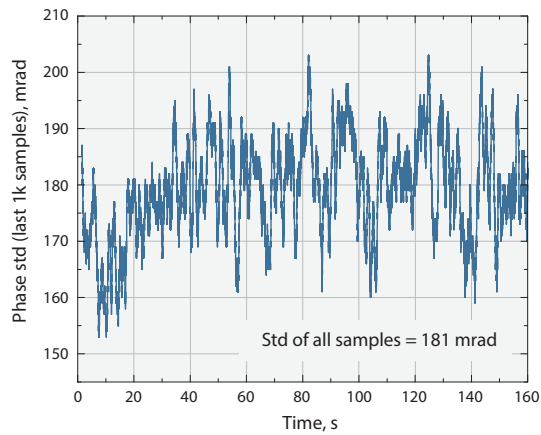
Short term pulse-to-pulse energy stability of PHAROS lasers. 1.2×10^7 pulses (1 min at 200 kHz), STD < 0.11%, peak-to-peak < 1%



Carrier-envelope phase (CEP) over the long period with active phase stabilization system



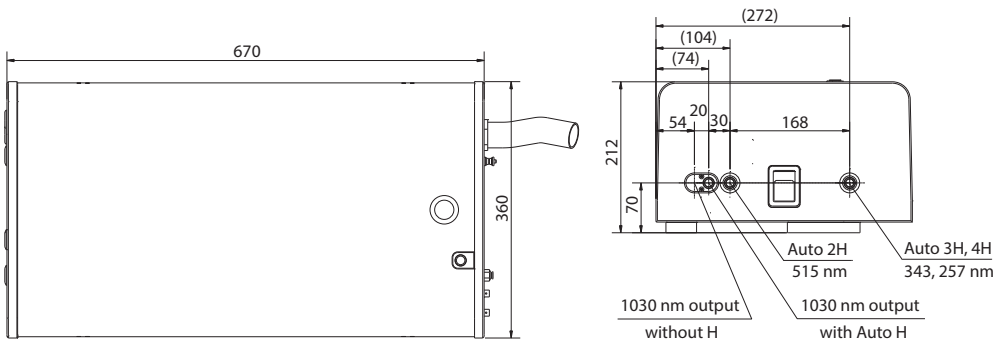
CEP stability over a long time scale



CEP stability over a short time scale

PHAROS CEP stability when laser is isolated from all noticeable noise sources – vibrations, acoustics, air circulation and electrical noise. System can achieve < 300 mrad std of CEP stability over a long time scale (> 8 hours) and < 200 mrad over a short time scale (< 5 min)

OUTLINE DRAWINGS



PHAROS PH1 laser outline drawing

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